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twice that  
ers were  
unique, and  
temperature.

Factorily predict the observed dependence upon  
hole concentration. This discrepancy can be  
qualitatively explained if one takes into ac-  
count the probable geometry of the hole Fermi  
surface for the overlapping valence band.

\*This research was conducted under the McDon-  
nell Douglas Independent Research and Develop-  
ment Program.

FF 4 Galvanomagnetic Measurements at Hydrostatic Pressure  
on  $Hg_{1-x}Cd_xTe$  Alloys Near the Semimetal-Semiconductor  
Transition. C. T. ELLIOTT,† JOHN MELNGAILIS, T. C.  
HARMAN and J. A. KAFALAS, Lincoln Laboratory, M.I.T.--  
The variation of Hall coefficient, R, and resistivity with mag-  
netic field has been measured at pressures up to 9 kbar on p-  
type  $Hg_{1-x}Cd_xTe$  samples with x in the range 0.14 to 0.17. Re-  
sults have been obtained at 77°K, 4.2°K and 1.3°K. A sharp  
rise in the plots of resistivity vs. pressure and an abrupt  
change in the sign of R identify the semimetal-semiconductor  
transition (which at 4.2°K and x = 0.14 occurs at 8 kbar).  
From an analysis of the data using multiband models the varia-  
tion of electron concentration with pressure has been obtained.  
This variation of electron concentration, over more than two  
orders of magnitude, is compared with theoretical predictions  
using the Kane model. At high pressures, where the electron  
concentration is negligible, good fits to the experimental data  
are obtained using a two hole band model, e.g., in a sample  
with x = 0.14 at 9 kbar and 4.2°K the light and heavy hole con-  
centrations are found to be  $3.6 \times 10^{12} \text{ cm}^{-3}$  and  $2.7 \times 10^{17}$   
 $\text{cm}^{-3}$  respectively. Carrier freeze-out is observed in this  
extrinsic region.

\*This work was sponsored by the Department of the Air Force.  
†Permanent address: Royal Radar Establishment, England.

FF 5 High-Mobility Layers of PbTe and  $Pb_{1-x}Sn_xTe$

H. HOLLOWAY and E. M. LOGOTHETIS, Ford Motor Company,  
Dearborn, Michigan. -- High mobility epitaxial layers of  
PbTe and  $Pb_{1-x}Sn_xTe$  (with x  $\approx$  0.2) have been prepared by  
post-growth annealing. Typically, layers 1-7  $\mu\text{m}$  thick  
were grown on cleaved  $BaF_2$  and then heated in vacuo at  
300-350°C for 20-100 hrs. Unlike as-grown layers, these  
specimens retain bulk values of the Hall mobility at  
temperatures down to 50°K with saturation values greater  
than  $10^5 \text{ cm}^2 \text{ V}^{-1} \text{ sec}^{-1}$ . This result contrasts with previous  
reports that layers of IV-VI compounds on alkali halide  
substrates have mobilities that are decreased by post-  
growth heating. The difference appears to arise from  
differences in the match between the thermal expansion  
coefficient of the substrate and that of the deposit.  
Thus, the increased mobilities of layers on  $BaF_2$  may be  
attributed to increase of the sub-grain size in the  
epitaxial layer during annealing and the failure to  
observe the effect with layers on alkali halides is  
probably a consequence of masking by damage introduced  
by differential contraction after the anneal. These  
results have potential application to  $Pb_{1-x}Sn_xTe$  photo-  
conductors.

FF 6 Compensation and Ionized Defect Scattering in  
PbTe and Other IV-VI Compounds. E. M. LOGOTHETIS and  
H. HOLLOWAY, Ford Motor Company, Dearborn, Michigan. --  
Analysis of annealing data for PbTe predicts compensa-  
tion of native defects that depends on the thermal  
history. A model of ionized defect scattering in cubic  
IV-VI compounds (possessing 4 equivalent anisotropic  
bands) is developed for arbitrary degeneracy by intro-  
ducing longitudinal and transverse relaxation times.  
Non-parabolic effects are neglected which limits the  
applicability of the theory to carrier concentrations  
 $\leq 5 \times 10^{19} \text{ cm}^{-3}$ . Experimental low temperature mobili-  
ties of PbTe, PbSe and PbS are in good agreement with  
the theory. The inclusion of compensation in our  
model can explain the PbTe mobility results of  
Kobayashi et al.<sup>1</sup> who observed an increase in mobility  
with carrier concentration  $< 10^{19} \text{ cm}^{-3}$ , and the wide

range of values of the low temperature mobility that  
has been observed in PbTe and other IV-VI compounds.

<sup>1</sup>A. Kobayashi et al., Proc. Inter. Conf. Sem., Paris  
(1964) p. 1257.

FF 7 Transport Measurements and Electroluminescence  
in n-type Gallium Phosphide-Zinc Selenide Alloys.  
PHIL WON YU, MAURICE GLICKSMAN, and AARON WOLD, Brown  
Univ.-- Electrical measurements were made in the tem-  
perature range 8-360 K for crystalline samples of  
alloys with low ZnSe content (below 5%). The tem-  
perature dependence of the mobility shows the domi-  
nance of ionized impurity scattering over the tempera-  
ture range 130-250 K. The mobility is a monotonically  
increasing function of temperature in the range 50-  
250 K and indicates possible hopping contributions to  
the conductivity below 50 K. Diodes were prepared by  
Zinc diffusion. Weak electroluminescence in the  
visible range of the spectrum was observed.

\*Work supported in part by NASA under Grant No. NGR  
40-002-094.

FF 8 Non-Ohmic Transport and Current Controlled  
Negative Resistance in CdSe. R. P. KHOSLA, J. R.  
FISCHER and B. C. BURKEY, Eastman Kodak Company.--We  
have measured the conductivity, Hall coefficient and  
mobility of CdSe samples, varying in electron concen-  
tration from  $3 \times 10^{16}$  to  $1.1 \times 10^{17} \text{ cm}^{-3}$ , under high  
electric fields at low temperatures. The conductivity  
shows non-ohmic behavior beyond 3-5 V/cm; at the same  
field the Hall coefficient starts to increase, but  
decreases rapidly beyond 100 V/cm. At about 120 V/cm,  
breakdown takes place and the samples show a region of  
current controlled negative resistance (CCNR). A dis-  
cussion will be given of the non-ohmic transport in  
terms of the various scattering mechanisms and the  
subsequent CCNR due to the impact ionization of the  
shallow donors.

FF 9 Photocarrier Multiplication Due to Impact  
Ionization of the Shallow Donors in CdSe. J. R. FISCHER  
and R. P. KHOSLA, Eastman Kodak Company.--In the pre-  
vious paper we reported the observance of current con-  
trolled negative resistance (CCNR) in CdSe. This was  
attributed to the impact ionization of the shallow  
donors. It is found that under band gap illumination,  
large photocarrier multiplication can take place.  
Photogains (number of electrons)  $\approx 10^4$  are obtained. The  
photogain increases with decreasing temperature. These  
results can be understood qualitatively in terms of the  
model proposed by Crandall<sup>1</sup> in which the photoexcited  
carriers screen the electron-ionized impurity and the  
electron-phonon interactions. This leads to a hotter  
electron distribution and increased impact ionization of  
the shallow donors which, in turn, cause the sample to  
switch from its low current to a high current stage.  
The effect of light intensity and the concentration de-  
pendence of the photogains will be discussed.

<sup>1</sup>R. S. Crandall, J. Phys. Chem. Solids, 31, 2069 (1970).

FF 10 Thermal Conductivity of  $Mg_2Ge$  and  $Mg_2Si$ . J. J.  
MARTIN, Okla. State Univ.--The lattice thermal conductiv-  
ities of the semiconductors  $Mg_2Ge$  and  $Mg_2Si$  have been  
measured from 3 to 200K. Neutral donor-phonon scattering  
was observed in  $Mg_2Ge$  by comparing the results for an al-  
doped crystal,  $n_d = 5 \times 10^{16} \text{ cm}^{-3}$  with an undoped crystal,  
 $n_d = 5 \times 10^{14} \text{ cm}^{-3}$ . The  $Mg_2Si$  crystal contained several  
low angle grain boundaries which masked any possible  
electronic scattering effects. The lattice conductivi-